
AMENDMENT TO THE CLAIMS

Claims 1-6 (canceled).

Claims 7-10 (withdrawn).

Claim 11-13 (canceled).

Claim 14 (previously added): The sputtering target according to claim ~~14~~ 27, wherein said alloy contains multiple phases comprising CoB, CoCrB, CoCr, CoPt, CoCrPt, and Pt uniformly distributed in the alloy.

Claim 15 (canceled).

Claim 16 (amended): The sputtering target according to claim ~~17~~ 27, wherein said alloy further includes tantalum and said alloy comprises Co-20Cr-10Pt-2Ta-5B.

Claim 17 (canceled).

Claim 18 (amended): The sputtering target according to claim ~~17~~ 28, wherein said alloy comprises Co-19Cr-11Pt-8B.

Claim 19 (amended): The sputtering target according to claim ~~17~~ 28, wherein said alloy comprises Co-15Cr-11Pt-10B.

Claim 20 (amended): The sputtering target according to claim ~~7~~ 28, wherein said alloy comprises Co-20Cr-10Pt-6B.

Claim 21 (amended): The sputtering target according to claim 7 28, wherein said alloy comprises Co-10Cr-10Pt-20B.

Claim 22 (amended): The sputtering target according to claim 7 28, wherein said alloy comprises Co-12Cr-12Pt-18B.

Claim 23 (amended): The sputtering target according to claim 7 28, wherein said alloy comprises Co-12Cr-8Pt-22B.

Claim 24 (amended): The sputtering target according to claim ~~14~~ 27, wherein the atomic % of B ranges from 2 atomic % to 30 atomic %.

Claim 25 and 26 (canceled).

Claim 27 (new): A precious metal magnetic sputtering target comprising a mechanically alloyed, chemically homogeneous alloy composition having microstructural homogeneity, said alloy composition comprising Pt, Co, Cr, and at least 2 atomic % B.

Claim 28 (new): The sputtering target according to claim 27, wherein the atomic % of B is at least 6 atomic %.
